



PATENT

In re Patent of:

Shinichi SHIMA

Application No.: 09/986,958

Filed: November 13, 2001

For: EXPOSURE APPARATUS, METHOD OF )  
MANUFACTURING SEMICONDUCTOR DEVICES, :  
SEMICONDUCTOR MANUFACTURING PLANT, )  
METHOD OF MAINTAINING EXPOSURE :  
APPARATUS, AND POSITION DETECTOR )

U.S. Patent No. 6,822,727 B2

Issued: November 23, 2004

Examiner: H. Nguyen

Group Art Unit: 2851

February 28, 2005

**Certificate**  
**MAR 03 2005**  
**of Correction**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450  
**Attention: Certificate of Correction Branch**

REQUEST FOR  
CERTIFICATE OF CORRECTION  
UNDER RULES 322 AND 323

Sir:

Patentee requests that a Certificate of Correction be issued by the Patent and Trademark Office due to errors which appear in the printed patent as a result of Patent and Trademark Office mistakes and mistakes of a minor nature which are not the fault of the Patent and Trademark Office. A Certificate of Correction form, in duplicate, is enclosed.

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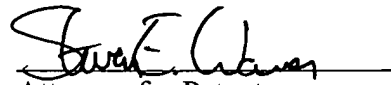
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Accompanying this letter is a check for \$100.00 to cover the statutory fee for such Certificate of Correction. Any additional fee required by this paper may be charged to Deposit Account No. 06-1205. A duplicate of this paper is enclosed for that purpose.

Patentee's undersigned attorney may be reached in our Washington, D.C. Office by telephone at (202) 530-1010. All correspondence should continue to be directed to our below-listed address.

Respectfully submitted,

  
Attorney for Patentee  
Steven E. Warner  
Registration No. 33,326

FITZPATRICK, CELLA, HARPER & SCINTO  
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New York, New York 10112-3801  
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DATED : November 23, 2004

INVENTOR(S): Shinichi SHIMA

Page 1 of 8

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Line 47, "prior-art" should read -- prior art --.

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Line 27, "where" should read -- wherein --.

COLUMN 8:

Line 29, "for various" should read -- for performing various --.

COLUMN 10:

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Line 57, "in highly" should read -- in a highly --.

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Line 27, "and lower" should read -- and to lower --.  
Line 32, "preferably" should read -- preferably, --.  
Line 41, "In case" should read -- In the case --.  
Line 55, "and lower" should read -- and to lower --.

COLUMN 15:

Line 58, "where" should read -- wherein --.

COLUMN 16:

Line 62, "spaces 69, 70" should read -- spaces 69, 70, --.

COLUMN 17:

Line 3, "spaces therefore" should read -- spaces, therefore, --.  
Line 53, "FIG. 9B." should read -- FIG. 9B, --.  
Line 56, "opposite the" should read -- opposite to the --.  
Line 62, "namely" should read -- namely, --.

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COLUMN 18:

Line 42, "opposite the" should read -- opposite to the --.

Line 52, "that LW2" should read -- that length LW2 --.

COLUMN 19:

Line 33, "space" should read -- the space --.

Line 49, "of large" should read -- of a large --.

Line 59, "of Semiconductor" should read -- of a Semiconductor --.

Line 61, "eg., (semiconductor)" should read -- (e.g., semiconductor --.

COLUMN 20:

Line 9, "eg., (lithographic)" should read -- (e.g., lithographic --.

Line 12, "etc.)" should read -- etc.), --.

Line 13, "eg., (assembly)" should read -- (e.g., assembly --.

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It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

COLUMN 21:

Line 15, "manufacturing" should read -- the manufacturing -- and "of semiconductor" should read -- of a semiconductor --.

Line 16, "devices)." should read -- device). --.

Line 27, "maker **210**, resist" should read -- maker **210**, a resist --.

Line 28, "and thin-film" should read -- and a thin-film --.

Line 30, "for remote" should read -- for performing remote --.

COLUMN 22:

Line 2, "vender," should read -- vendor, --.

Line 9, "Manufacturing Semiconductor" should read -- Manufacturing a Semiconductor --.

Line 27, "and durability" should read -- and a durability --.

COLUMN 24:

Line 15, "detections" should read -- detection --.

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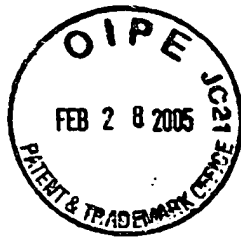
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Shinichi SHIMA ) Examiner: H. Nguyen  
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Application No.: 09/986,958 ) Group Art Unit: 2851  
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Respectfully submitted,

  
Attorney for Patentee  
Steven E. Warner  
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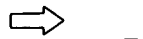
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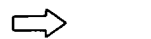
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Line 9, "eg., (lithographic)" should read -- (e.g., lithographic --.

Line 12, "etc.)" should read -- etc.), --.

Line 13, "eg., (assembly)" should read -- (e.g., assembly --.

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PATENT NO. 6,822,727 B2

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**CERTIFICATE OF CORRECTION**

PATENT NO. : 6,822,727 B2

DATED : November 23, 2004

INVENTOR(S): Shinichi SHIMA

Page 8 of 8

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

COLUMN 21:

Line 15, "manufacturing" should read -- the manufacturing -- and "of semiconductor" should read -- of a semiconductor --.

Line 16, "devices)." should read -- device). --.

Line 27, "maker **210**, resist" should read -- maker **210**, a resist --.

Line 28, "and thin-film" should read -- and a thin-film --.

Line 30, "for remote" should read -- for performing remote --.

COLUMN 22:

Line 2, "vender," should read -- vendor, --.

Line 9, "Manufacturing Semiconductor" should read -- Manufacturing a Semiconductor --.

Line 27, "and durability" should read -- and a durability --.

COLUMN 24:

Line 15, "detections" should read -- detection --.

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